Drivers of Materials R&D

The basic set of motivating questions:

- 1. What material features produce quenches, increase in Rs?
- 2. How do we prevent the material features above from occurring? What material forming and/or processing methods can minimize the occurrence of the above, for the minimum cost?
- 3. How are surface resistance (Rs) and Q(E) affected by
 - impurities? grain boundaries? surface layers? topography and length scale?
 - secondary or combined effects (e.g. diffusion of impurities down grain boundaries)?
- 4. How do we describe the target surface and how can it be obtained reliably?
- 5. How can we make various characterizations relevant? How do we do this easily without destroying the cavity or causing it to be re-processed?

General issues

- What is useful, and what is immediately applicable?
 - Projects in planning phase: 3 year window (or so)
 - HEP stewardship of accelerator technology: long term capability
- Making coupons relevant to cavities
 - Need coupon Q vs E

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- Mushroom cavities at Cornell, TAMU, Stanford, Scanned-probe Q vs E
- Need cavity spectroscopy (topography is now available!)
 - Cut-outs from single cells
- Need coupon forming and chemical processing same as cavity forming and processing
 - Coupons are generally annealed, cavities are generally cold-worked before welding
- Maximize useful cavities, minimize cost
 - Prevent defects, Repair known defects
 - Processing at what cost? Future: CBP or BCP, with final EP
 - CBP or BCP to prescribed roughness to set up EP, EP at 25 C or colder

Session 1.

Materials issues from cavity tests

- 1.3 GHz paradigm: maximize gradient at $Q \sim 10^{10}$
 - Several 9-cell cavities being processed to >40 MV/m; performance depends on facility
 - Many 1-cell cavities being processed to >40 MV/m; this is now expected from all facilities
 - Quenches at lower gradients remain; they often occur at specific locations and are correlated with visible defects (pits, stains, etc)
 - Investigate origin of defects to prevent them
 - Reduce processing errors
 - Field Emission addressed with HPR; system issue, model it, develop remediation or preventative measures
 - Is there a field-emission-proof surface? Polymeric films?
- 650 MHz paradigm: reduce R_s
 - 3 times more niobium; opportunity for films?
 - Spokes too
 - Modest gradient: different processing paradigm? Probably not pushing the technology, just pushing the cost issues
 - Need to update thermal conductivity and R_s data and R_{BCS} (T), Q(E) at different temperatures
 - Need non-linear BCS model of surface resistance

Session 1. Materials issues, cavity tests - 2

- Topography might not be the chief materials challenge
 - 40 to 40,000 nm, all sizes and shapes... does this depend on frequency?
 - Tumbled cavity with awful surface and 40 MV/m

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- FNAL will be cutting out samples from cavity quench locations and control locations for spectroscopy analyses
- Cavity baking might consider 2 steps: removal of bulk hydrogen, and removal of *surface* hydrogen
 - Both are accomplished at 800 °C; with other changes (Rv, Rx) the combination leads to higher gradient
 - Surface hydrogen New implications for hydrogen-vacancy and vacancydislocation interactions mean new implications for 120 °C bake, too
- How, or where, pits cause quench might be more complex than we have thought
 - By admitting flux, might the quench location move elsewhere? Test with different cooling procedures